

# PRESS RELEASE

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## **Micronic receives an order for an Omega6005 for versatile semiconductor photomasks**

Täby, Sweden, December 21, 2000 — Micronic Laser Systems AB (OM Stockholm Exchange: MICR), a company at the forefront of semiconductor and display laser pattern generators for the production of photomasks to the worldwide electronic industry, today announced that it has received an order for an Omega6005 laser pattern generator from a Japanese maskshop. The system will be used for versatile photomask manufacturing for semiconductor applications. Delivery will take place during the later part 2001.

“This order from an existing customer confirms the strength of our product mix from Omega6005 to the most advanced Omega6600 which accommodate the semiconductor industry requirements from 0.5 to 0.15  $\mu\text{m}$  technology nodes”, says Bert Jeppsson, President and CEO of Micronic.

### **About Micronic Laser Systems**

Micronic Laser Systems is a Swedish high-tech company engaged in the development, manufacture and marketing of a series of extremely accurate laser pattern generators for the production of photomasks. The technology involved is known as microlithography. Micronic's systems are used by the world's leading electronics companies in the manufacture of television and computer displays, semiconductor circuits and semiconductor packaging components. Micronic is located in Täby, north of Stockholm and has subsidiaries in the United States, Japan and Taiwan. Micronic is projecting to almost triple its net sales from MSEK 213 in 1999 to exceed MSEK 600 for year 2000. Micronic also announced a projected strong improvement of the operating margin for the full year. Micronic has around 260 employees worldwide. Micronic maintains a web-site at: [www.micronic.se](http://www.micronic.se)